



Device Material Content

5555 NE Moore Ct.
Hillsboro OR 97124
custreq@latticesemi.com

Assembly: ASEM
Size (mm): 17 x 17

Package: **400 caBGA**
Total Device Weight **0.747** Grams

Package Code:

BG400

Lead pitch (mm): 0.8

MSL: 3

January, 2020

Products:

XO3

Reflow max (°C): 260

	% of Total Pkg. Wt.	Weight (g)	% of Total Pkg. Wt.	Weight (g)	Substance	CAS #	% of Subst.	Notes / Assumptions:
Die	1.39%	0.0104	1.39%	0.0104	Silicon chip	7440-21-3	100.00%	Die size: 4.4 x 4.3 mm
Mold Compound	51.80%	0.3871	3.63%	0.0271	Epoxy Resin	-	7.00%	Mold Compound: Sumitomo G750SE (ULA)
			2.59%	0.0194	Phenol Novolac	9003-35-4	5.00%	
			2.59%	0.0194	Metal Hydroxide	-	5.00%	
			0.26%	0.0019	Carbon Black	1333-86-4	0.50%	
			42.74%	0.3194	Silica Fused	60676-86-0	82.50%	
D/A Epoxy	0.21%	0.0016	0.17%	0.00126	Silver	7440-22-4	80.00%	Die attach epoxy: Henkel (Ablebond) 2100A
			0.04%	0.00031	Esters & resins	-	20.00%	
Wire	0.72%	0.0054	0.70%	0.0053	Copper	7440-50-8	97.90%	0.8 mil diameter; 1 wire per solder ball
			0.02%	0.0001	Palladium	7440-05-3	2.10%	
Solder Balls	20.03%	0.1497	19.33%	0.1444	Tin (Sn)	7440-31-5	96.50%	SAC305
			0.60%	0.0045	Silver (Ag)	7440-22-4	3.00%	
			0.10%	0.0007	Copper (Cu)	7440-50-8	0.50%	
Substrate	16.80%	0.1256	0.00%	0.0000	BT Resins	-	32.00%	BT Resin CCL-HL832NX-A*
			0.00%	0.0000	Glass fiber	65997-17-3	68.00%	
Foil	6.28%	0.0469	5.31%	0.0397	Copper	7440-50-8	84.56%	
			0.92%	0.0069	Nickel plating	7440-02-0	14.70%	
			0.05%	0.0003	Gold plating	7440-57-5	0.74%	
Solder Mask	2.77%	0.0207	1.51%	0.0112	Quartz	14808-60-7	54.37%	Solder mask PSR4000 AUS 308
			0.20%	0.0015	Dipropylene glycol monomethyl ether	34590-94-8	7.33%	
			0.09%	0.0007	Morpholine derivative**	71868-10-5	3.32%	
			0.08%	0.0006	Silicon dioxide	7631-86-9	3.00%	
			0.08%	0.0006	Silica, amorphous	112945-52-5	3.00%	
			0.01%	0.00005	Carbon black	1333-86-4	0.24%	
			0.80%	0.0059	Trade secret ingredients	-	28.74%	

Notes: SVHC: * 0.17% max. concentration of Bisphenol A (CAS# 80-05-7), contained in substrate laminate material as impurity - not intentionally added.
** 0.09% max. concentration of Morpholine derivative (CAS# 71868-10-5), contained in solder mask material.

Lattice regards this materials information to be correct but makes no guarantee as to its accuracy or completeness, including, but not limited to, with respect to its compliance with applicable environmental laws and regulations. Lattice subcontracts the production, test and assembly of hardware devices to independent third-party vendors and materials suppliers ("Contractors"). All data provided hereunder is based on information received from Contractors. Lattice has not independently verified the accuracy or completeness of this information which is provided solely for your reference in connection with the use of Lattice products.

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Mold Compound	51.80%	0.3871	3.63%	0.0271	Solid Epoxy Resin	-	7.00%	Mold Compound: Hitachi GE-110LS-V (ULA)
			2.59%	0.0194	Phenol Resin	-	5.00%	
			44.03%	0.3290	Silica	60676-86-0	85.00%	
			1.30%	0.0097	Metal Hydroxide	-	2.50%	
			0.26%	0.0019	Carbon Black	1333-86-4	0.50%	
D/A Epoxy	0.21%	0.0016	0.17%	0.00126	Silver	7440-22-4	80.00%	Die attach epoxy: Ablebond 2300
			0.04%	0.00031	Esters & resins	-	20.00%	
Wire	0.72%	0.0054	0.70%	0.0053	Copper	7440-50-8	97.90%	0.8 mil diameter; 1 wire per solder ball
			0.02%	0.0001	Palladium	7440-05-3	2.10%	
Solder Balls	20.03%	0.1497	19.73%	0.1474	Tin (Sn)	7440-31-5	98.50%	SAC105
			0.20%	0.0015	Silver (Ag)	7440-22-4	1.00%	
			0.10%	0.0007	Copper (Cu)	7440-50-8	0.50%	
Substrate	16.80%	0.1256	5.38%	0.0402	BT Resins	-	32.00%	BT Resin CCL-HL832NX-A*
			11.43%	0.0854	Glass fiber	65997-17-3	68.00%	
Foil	6.28%	0.0469	5.31%	0.0397	Copper	7440-50-8	84.56%	
			0.92%	0.0069	Nickel plating	7440-02-0	14.70%	
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